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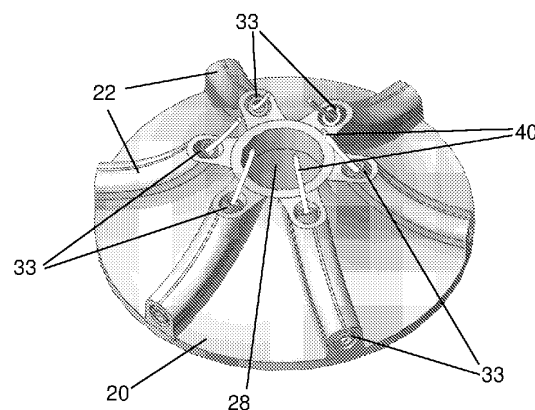


FIG. 9

(57) Abstract: A polishing tool comprising: a rubber pad provided with a number of channels; and a corresponding number of stiffeners receivable in the channels to slidably engage the channels; wherein increase in length of the stiffeners in the channels increases stiffness and decreases compliance of the rubber pad.

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